

United States Patent and Trademark Office

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/720,191	11/25/2003	Hun-Suk Yoo	6161.0099.US	4232
58027	7590 08/17/2006		EXAMINER	
H.C. PARK & ASSOCIATES, PLC			ROY, SIKHA	
8500 LEESE SUITE 7500			ART UNIT	PAPER NUMBER
VIENNA, V			2879	
			DATE MAILED: 08/17/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)		
Office Action Summary		10/720,191	YOO ET AL.		
		Examiner	Art Unit		
		Sikha Roy	2879		
Period fo	The MAILING DATE of this communication or Reply	appears on the cover sheet with the c	orrespondence address		
WHIC - Exter after - If NO - Failu Any r	ORTENED STATUTORY PERIOD FOR RECHEVER IS LONGER, FROM THE MAILING asions of time may be available under the provisions of 37 CFF SIX (6) MONTHS from the mailing date of this communication period for reply is specified above, the maximum statutory per re to reply within the set or extended period for reply will, by strepty received by the Office later than three months after the med patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATION R 1.136(a). In no event, however, may a reply be tin riod will apply and will expire SIX (6) MONTHS from atute, cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).		
Status					
2a)⊠	Responsive to communication(s) filed on <u>0</u> . This action is FINAL . 2b) 17. Since this application is in condition for allo closed in accordance with the practice under	This action is non-final. wance except for formal matters, pro			
Dispositi	on of Claims				
5)□ 6)⊠ 7)□ 8)□ Applicati	Claim(s) 1-20 is/are pending in the applicate 4a) Of the above claim(s) 10-20 is/are without Claim(s) is/are allowed. Claim(s) 1-9 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and on Papers The specification is objected to by the Example of the drawing(s) filed on is/are: a) are subject to restriction.	drawn from consideration. ad/or election requirement.	Evaminor		
	Applicant may not request that any objection to Replacement drawing sheet(s) including the cor The oath or declaration is objected to by the	the drawing(s) be held in abeyance. See rection is required if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).		
Priority u	ınder 35 U.S.C. § 119				
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
2) 🔲 Notice 3) 🔲 Inforn	(s) e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/ No(s)/Mail Date				

DETAILED ACTION

Response to Amendment

The Amendment, filed on June 6, 2006 has been entered and acknowledged by the Examiner.

Claims 10-20 are withdrawn.

Claims 1-9 are pending in the instant application.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1,3,4,5, 7-9 are rejected under 35 U.S.C. 103(a) as being unpatentable over JP 2001319583 to Kado et al.

Regarding claim 1 Kado discloses (Figs. 1,7 English translation para [0041], [0052],[0053],[0062]) a plasma display panel comprising a first substrate 10 and a second substrate 20 opposing one another with a predetermined gap there between and a sealant (glass layer) formed on opposing surfaces of the first and second substrates around an outer circumferential area of the first and second substrates to seal them wherein the sealant is formed of regions 62 having a first width of substantially same size and regions having a second width 64, second width being greater than the first width.

Kado does not explicitly disclose the sealant is formed having substantially uniform thickness. But Kado discloses (para [0053]) the display panel is sealed by conventional sealing approach and it is noted that (as also has been disclosed by the applicant in prior art section page 2 lines 14-16) conventionally sealant is applied between the two substrates with uniform thickness (with no depressions or protrusions) so that when sealed two substrates are leveled and produces a planar display. Therefore it would have been obvious to one of ordinary skill in the art at the time of invention to specify the two substrates of Kado are sealed having regions of different widths but uniform thickness of the sealant.

Regarding claim 3 Kado discloses in Fig. 7 that plurality of regions of the sealant having second width are formed at pre-determined intervals around the circumferential area of the first and second substrates.

Regarding claim 4 it is clearly evident from Fig. 7 that when moving on one direction along the long axis of the sealant, regions with second width gradually increases in size from regions having first width until reaching the size of the second width and the width of the sealant gradually decreases in size until it reaches the size of the first width.

Regarding claim 5 Kado discloses (para [0006]) the sealant is a sealing glass frit.

Regarding claim 7 Kado discloses the limitations which are same as those of claim 1 and further discloses (Figs. 3B, 6A) the cross-section of the sealant is band-shaped with a plurality of nodes in glass layer 64.

Regarding claim 8 Kado discloses (Fig. 3B) the nodes 61 are formed at predetermined intervals around the peripheral areas of the first and second substrate.

Regarding claim 9 Kado discloses (column 7 line 45) the sealant is a sealing glass frit.

Claims 2 and 6 rejected under 35 U.S.C. 103(a) as being unpatentable over JP 2001319583 to Kado et al. and further in view of U.S. Patent 6,817,917 to Kado et al. (referred as '917).

Regarding claim 2 Kado is silent about regions of sealant having second width being located at area where a sealing pressure is concentrated.

Kado ('917) in same field of endeavor discloses (Fig. 10 column 12 lines 29-51) clamps 50 along the circumference of the first and second substrate 10, 20 are used to hold the substrates 10,20 aligned.

It is well known in the art that sealing clamps mounted along the peripheral region are used for applying a predetermined pressure so as to maintain a combination/attachment state between the first and second substrates. It is noted that the sealing pressure provided by the sealing clamps can be applied more effectively where the sealing frit mass is more. Therefore it would have been obvious tone of ordinary skill in the art at the time of invention to apply the sealing pressure in the regions of the sealant having second width with more sealant than the regions of the first width of Kado for applying predetermined pressure more effectively.

Regarding claim 6 it would have been obvious to specify the locations of the sealing clips of Kado ('917) mounted to the first and second substrates at the regions of

the second widths of the sealant of Kado for applying predetermined pressure more effectively between and hence better alignment of the substrates.

Response to Arguments

Applicant's arguments with respect to claims 1 and 7 have been considered but are most in view of the new ground(s) of rejection.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. U.S. Patent 6,809,476 to Lee et al. and U.S. Patent Application Publication 20040056597 to Ko et al. disclose method of fabricating plasma display panel including sealant between the substrates and using sealing clips for alignment of the substrates.

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any

Application/Control Number: 10/720,191 Page 6

Art Unit: 2879

extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Contact Information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sikha Roy whose telephone number is (571) 272-2463. The examiner can normally be reached on Monday-Friday 8:00 a.m. – 4:30 p.m.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nimeshkumar D. Patel can be reached on (571) 272-2457. The fax phone number for the organization is (571) 273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Sikha Roy

Sikha Roy Patent Examiner Art Unit 2879